

Vibration Control of Flexible Base Mobile Manipulators under Impedance Controller Using New Control Element on the End Effector

M. Salehi , G. R. Vossoughi

Abstract — In this paper new method for vibration control of Flexible Base Mobile Manipulator (FBMM) under constrained motion control were proposed. When robotic manipulator with base flexibility contacts environment under impedance control, vibration occurs at transient and contact moments. Vibration causes position and force inaccuracy, instability and servicing requirements of equipment. Previous active vibration control is based on vibration control elements on the base of manipulator. As new method, control element on the manipulator's End Effector was proposed for vibration control and vibration damping on the mechanism. This controller includes same or better response and lower control coefficients because of its performance on the End Effector instead of the base.

Active Vibration Controller on the End Effector (AVEE) was simulated for two models. First model is a simple FBMM composed of a 2 DOFs planar manipulator and a single DOF moving base with flexibility in between. Second model is an advanced 10 DOF's FBMM. Combined Impedance/AVEE controller provides desired position/force control with satisfactory damped vibration especially at the point of contact. Results show that control coefficients of active vibration controller on the Base (AVCB) are so bigger than these coefficients for AVEE.

Index Terms — Mobile Manipulator, Vibration Control, Position/Force Control, Flexible base , End Effector

I. INTRODUCTION

Expanding the effective workspace is excellent specification of mobile manipulators. Moving base mobile manipulators such as macro/micro manipulators, space manipulators and underwater robotic vehicles can be used in finishing, repair and maintenance, inspection, welding, cleaning, and machining operations. Also, base of mobile robot is flexible and assumption of base rigidity is unreal. Flexibility and compliance of the base in most cases results in the loss of accuracy and limitations in achievable speeds. The source for base flexibility can be for example the suspension system and/or the internal structural flexibility of the base platform or joint/link flexibility associated with a supporting manipulator/crane in a macro/micro type manipulator arrangement.

As we know, all previous researches concentrated on the

vibration active control method on the manipulator's base. Hootsmans and Dubowsky considered the macro/micro manipulator and large mobile manipulator for joint motion controlling and decreasing the structural vibration in 1992. [1] Torres and Dubowsky proposed a simple damping algorithm for flexible base manipulator in 1996, but active feedback control on the base wasn't included. [2] Mavroidis and Dubowsky continued their researches and they proposed Inferred End-Point control for long reach manipulator with base vibration. [3]

Also, the pioneering work in stiffness /impedance control is by Salisbury and Hogen [4,5]. Kazerooni presented a frequency domain interpretation and design method, and proposed an implementation more suitable for use with industrial robots [6]. The problem of impedance control and dynamic stability of mobile manipulators (without flexibility) has been addressed by Inoue [7]. The concept of virtual / generalized impedance was proposed by Lao and Donath to avoid obstacles by redundant manipulators [8]. Modeling and impedance control of a two- manipulators system handling a flexible beam was addressed by Yan and Lin [9]. Multiple impedance control of cooperative manipulator in space was proposed by Mossavian, Papadaouplos and Poulakakis as an approach for handling large cargo in space [10]. To reduce contact forces in a mobile manipulators, simple damping-based posture control has been proposed by Kang and his colleagues [11]. Flexibility and active vibration control hasn't been considered in above investigations.

Jaydeep used adaptive coefficients for force control law and he achieved better response using this control law [12]. A research group at DLR Aerospace Research Centre have studied impedance control of light link manipulators with fixed base and joint flexibility. They proposed a new approach based on decoupled dynamics of torque and position errors [13,16]. Impedance control of rigid mobile manipulator was studied by Tan and his colleagues [14] and experimental results were presented with a mobile PUMA 560. Hang proposed a fuzzy control law for impedance control and was able to achieve a better response when impedance parameters were selected based on fuzzy rule base [15]. Vossoughi and Karimzadeh addressed the general impedance control of a flexible link manipulator using singular perturbation method and they presented simulation results of impedance control for a 2 DOF manipulator with fixed base [17].

A simple and high performance active vibration control hasn't been proposed under impedance control in all above researches for accurate position/force response. Of Course, Active vibration actuator on the manipulator's base has been

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selected for vibration damping, but active vibration control element on the End Effector proposed as first time with smaller control coefficients and same or better response. In this paper, a general dynamic model is considered for mobile manipulators with base flexibility. A new formulation for the impedance control based on Sliding Mode control theory (SMIC) is then addressed for achieving the desired impedance. Also, new active vibration control element on the End Effector (AVEE) is proposed. Better specification of combined SMIC/AVEE is simulated for a simple Flexible Base Moving Manipulator (FBMM), composed of a 2 DOF's planar manipulator mounted on a flexible 1 DOF base. Also, this controller is simulated for an advanced 10DOF's model. The better performance of the proposed controller during impact moments of manipulator's end Effector and the environment is also simulated.

II. GENERAL DYNAMIC MODEL

Nonlinear dynamic model of flexible base mobile manipulator was considered here as;

$$\begin{aligned} \tau &= M(X)\ddot{X} + C(X, \dot{X})\dot{X} + K(X)X + G(X) \\ &+ H(u_r, \dot{u}_r) \\ X &= [y, x_1, x_2, \dots, \theta_1, \theta_2, \dots]^T \\ \tau &= [0, F_1, F_2, \dots, \tau_1, \tau_2, \dots]^T \end{aligned} \quad (1)$$

Where, y is base flexibility vector, x_1, x_2, \dots are base movements in Cartesian coordinates, $\theta_1, \theta_2, \dots$ are angular movements of manipulator links, F_1, F_2, \dots are applied force to base and τ_1, τ_2, \dots are applies torque to links. M, C, K, G, H represent inertial matrix, damping and centrifugal and Coriolis terms matrix, stiffness matrix, gravity matrix and matrix of input road of base or so on.

If, we assume that mobile manipulator doesn't include any base flexibility and input roads, the slow dynamics of mobile manipulator will be derived as following relation:

$$\tau_{slow} = M(X)\ddot{X} + C(X, \dot{X})\dot{X} + G(X) \quad (2)$$

III. IMPEDANCE CONTROL

Impedance relation indicates desired impedance by matrices M_m, B_m, K_m, K_f :

$$\begin{aligned} M_m \ddot{e} + B_m \dot{e} + K_m e &= -K_f e_f \\ e &= x(t) - x_d(t) \\ e_f &= F(t) - F_d(t) \end{aligned} \quad (3)$$

M_m, B_m, K_m, K_f are impedance positive definite matrices and x_d, F_d are desired position and force vectors. Now, we consider combined sliding surface as following form:

$$s_c = \dot{e} + F_1 e + F_2 Z_c \quad (4)$$

So, following relation indicates compensating dynamics for combined sliding surface:

$$\dot{Z}_c = AZ_c + K_1 e + K_2 \dot{e} + K_3 e_f \quad (5)$$

K_1, K_2, K_3 are compensating positive matrices.

It must be considered $s = \dot{s} = 0$ for reaching to desired sliding mode:

$$\begin{aligned} \dot{Z}_c &= -F_2^{-1}(\ddot{e} + F_1 \dot{e}) \\ Z_c &= -F_2^{-1}(\dot{e} + F_1 e) \end{aligned} \quad (6)$$

We will have following relation by substituting equation (6) into equation (5);

$$\begin{aligned} \ddot{e} + (F_1 - F_2 A F_2^{-1} + F_2 K_2)\dot{e} + (F_2 K_1 - \\ - F_2 A F_2^{-1} F_1)e &= -F_2 K_3 e_f \end{aligned} \quad (7)$$

K_1, K_2, K_3 are specified by comparison between two relations (7) and (3) as desired impedance relations;

$$\begin{aligned} K_1 &= F_2^{-1} M_m^{-1} K_m + A F_2^{-1} F_1 \\ K_2 &= F_2^{-1} M_m^{-1} B_m - F_1 F_2 + A F_2^{-1} \\ K_3 &= F_2^{-1} M_m^{-1} K_f \end{aligned} \quad (8)$$

Sliding mode law was defined as following relation:

$$\dot{s}_c = -F(s_c) = -k \text{sat}(s_c) - \alpha s_c - \beta \int_0^t s_c dt \quad (9)$$

Where α, β, k are positive definite and diagonal matrices. Function sat is as below:

$$\text{sat}(s_c) = \begin{cases} \text{sign}(s_c) & |s_c / \phi| > 1 \\ s_c / \phi & |s_c / \phi| \leq 1 \end{cases} \quad (10)$$

Chattering coefficient, ϕ , is a positive definite vector for decreasing the changes of sliding surface variable.

Now, we propose sliding mode impedance control. We specify tracking error and then we will calculate desired acceleration vector of FBMM.

$$\begin{aligned} e &= x - x_d \\ \Rightarrow \dot{e} &= J(\Theta)\dot{\Theta} - \dot{x}_d \end{aligned} \quad (11)$$

$$\Rightarrow \ddot{e} = \dot{J}\Theta + J\ddot{\Theta} - \ddot{x}_d$$

Using sliding mode control law, desired acceleration vector is as following relation:

$$\begin{aligned} \dot{s} &= -F(s) = -k \text{sat}(s) - \alpha s = \ddot{e} + F_1 \dot{e} + F_2 \dot{Z} \\ \Rightarrow \dot{J}\Theta + J\ddot{\Theta} - \ddot{x}_d + F_1(J(\Theta)\dot{\Theta} - \dot{x}_d) + F_2 \dot{Z} &= -F(s) \\ \Rightarrow \ddot{\Theta} = \ddot{X} &= -J^{-1}(Ls + J\dot{\Theta}) \\ \rightarrow Ls = F_2 AZ + F_2 K_1 e + (F_1 + F_2 K_2)\dot{e} + F_2 K_3 e_f \\ - \ddot{x}_d + F(s) \end{aligned} \quad (12)$$

J is corresponding Jacobian Matrix of FBMM. Control torque/force vector indicates as following relation by substituting equation (12) into motion equation (2):

$$\tau_{\Theta} = -MJ^{-1}Ls + (C - MJ^{-1}J)\dot{\Theta} + G \quad (13)$$

IV. ACTIVE VIBRATION CONTROL ON THE BASE (AVCB)

We use Electro-mechanical or Hydro-electrical actuators for vibration damping using feedback control method. Base

vibration domain increases at the contact point and especially, vibration damping actuators is so necessary in these moments. Therefore, active combined vibration, position & force controllers are proposed for achieving to desired position and force accurately. Following relation is considered for Active Vibration Control of the manipulator's base (AVCB). Control forces could be applied by Hydro-electrical or Electro-mechanical elements.

$$F_b = -K_{bI}\ddot{y}_b - K_{bD}\dot{y}_b - K_{bP}y_b \quad (14)$$

F_b , y_b are control forces and vibration vector to the suspension points of the base. K_{bI}, K_{bD}, K_{bP} are vectors of PID or PI coefficients.

V. ACTIVE VIBRATION CONTROL ON THE END EFFECTOR (AVEE)

Control law is as following relation, related to vibration vectors of End Effector point. As a new method for active vibration control of robot at the contact moments, we use control element on the manipulator's End Effector.

$$F_e = -K_{eI}\ddot{y}_e - K_{eD}\dot{y}_e - K_{eP}y_e \quad (15)$$

F_e , y_e are control forces and vibration vector on the suspension points of the End Effector. K_{eI}, K_{eD}, K_{eP} are vectors of PID or PI coefficients of control element on the End Effector.

This control force is applied between End Effector and environment by AVEE. It is added to contact force at impact and contact moments by this feedback controller. We will show that the values of control coefficients for this control method are so smaller than the value of control coefficients of AVCB. Therefore, it is better and one point controller on the End Effector. Also, Simulation results show that AVEE provides better desired damping rate and stability guarantee at impact and contact moments.

Relations (8) show the solution existence of SMIC. So, combined position/force surface converge using these control coefficients and stability of proposed impedance sliding method guarantees. Also, proposed AVEE is a feedback PID controller and it is stable by using suitable control coefficients. Therefore, stability of whole dynamics guarantees under proposed SMIC/AVEE.

VI. SIMULATION RESULTS AND COMPARISON

First, a FBMM model is considered with 2 DOF's manipulator and single DOF base with flexibility in between. Model has been shown in Figure 1.

FBMM model specifications:

$$m_v=5 \text{ kg} ; m_b=2.5 \text{ kg} ; m_1=1 \text{ kg} ; m_2=1 \text{ kg} ; L_1=0.5 \text{ m} ; L_2=0.5 \text{ m} ; I_1=0.125 \text{ kg.m}^2 ; I_2=0.125 \text{ kg.m}^2 ; k=2000 \text{ N/m} ; c=100 \text{ N.sec/m} , g=9.81 \text{ m/sec}^2$$

Desired path is the motion of FBMM in direction x. End Effector of manipulator contacts the wall with stiffness coefficient $K=1000 \text{ N/m}$ in direction y. Then, End Effector

moves on the wall surface. Desired position and force on the wall are $y_d = x_{2d} = 0.8 \text{ m}$ and $F_d = 2.25 \text{ N}$. This is same application as painting, cleaning or welding.

Two cases were simulated by AVCB (Case 1) and AVEE (Case 2). Left column of following figures shows simulation results of case 1. Case 2 is indicated in right column. These simulation results indicate that desired position/contact force (Figures 2, 3 and 4, 5) were provided completely. Contact force on the wall surface is 2.5 N and y coordinate of the base was provided by both tow controllers. Active control forces of the base and End Effector are shown in Figures 8, 10. Maximum value and time of control force for case 2 is less than these values for Case 1. Maximum active force is about 1.71 N and control time is about 1.6 to 2.5 sec for AVCB. But these parameters are 1.52 N and 1.6 to 1.75 sec for better vibration response by AVEE.

New proposed impedance control model, SMIC provides desired position and force for two cases. But, combined SMIC/AVEE causes better response and damping effects using composed active vibration controller on the End Effector (Figure 6, 7, vibration for two cases). Figures 5 and 9 shows that vibration of the base and contact force were damped before 1.8 sec with same domain by AVEE. But, they were damped before 2.3 sec by AVCB (Figures 4, 6).

Accurate study proves that all dynamic and control parameters including state variables and control torques/forces have same or better response by new impedance/vibration control method, SMIC/ AVEE especially at contact points. Therefore, new combined controller causes better response for achieving to desired path and force. Other interesting result is lower value for feedback control coefficients of AVEE. It is simple and will be provided chipper, with lower effect of noise.

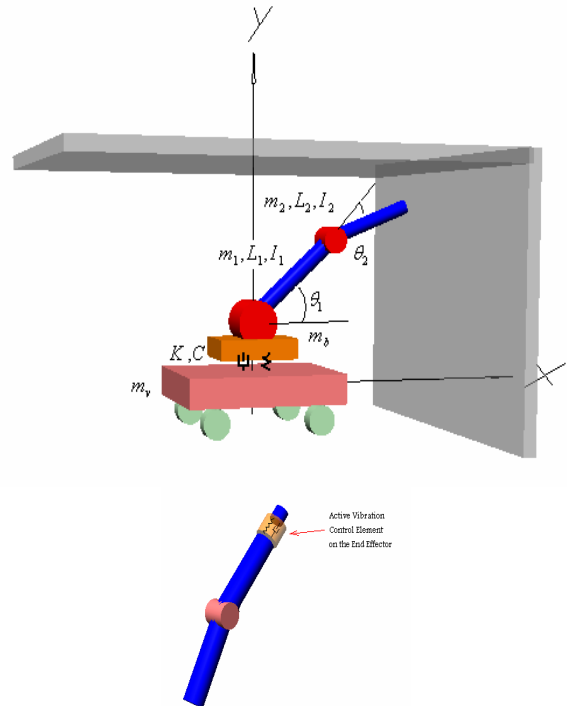


Fig. 1: FBMM model, $(x, y, \theta_1, \theta_2)$, AVEE element

Also, we selected an advance 10 DOF's model for simulation of sliding mode impedance control and active vibration control law on the End Effector. Figure 14 shows this model with 6 DOF's and flexibility on the base and 4 DOF's manipulator.

Case 1: SMIC/AVCB; Active Vibration Control of Mobile Manipulator on the base
 ($K_{bI} = 8, K_{bD} = 80, K_{bP} = 8$)

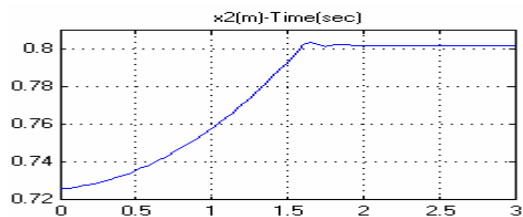


Fig. 2: y coordinate of End Effector

Case 2: SMIC/AVEE; Electro-mechanical Element as Active Vibration Control of Mobile Manipulator on the End Effector
 ($K_{eI} = 0.6, K_{eD} = 7, K_{eP} = 1$)

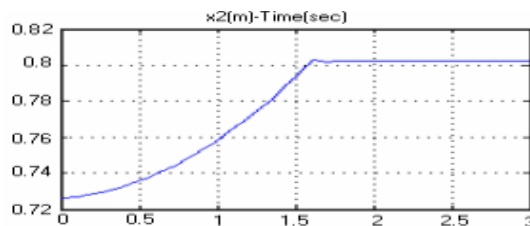


Fig 3: y coordinate of End Effector

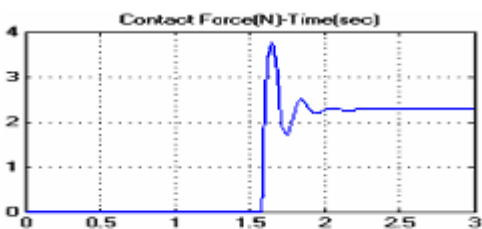


Fig 4: Contact Force between End Effector and roof

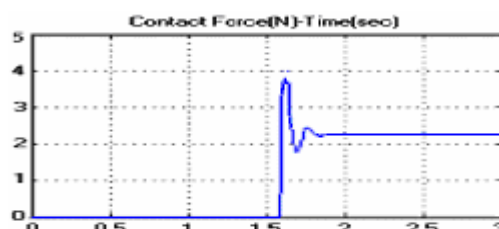


Fig 5: Contact Force between End Effector and roof

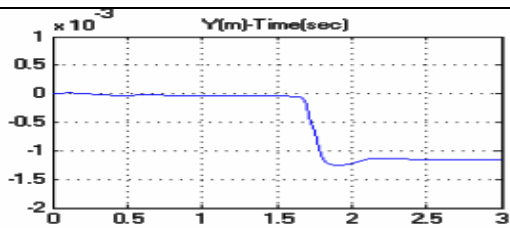


Fig 6: Vibration of Central mass of the base

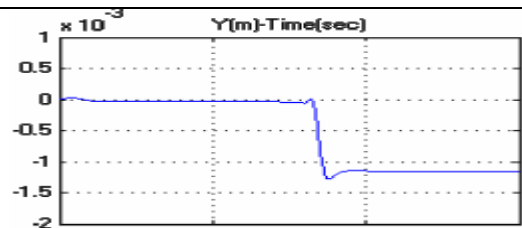


Fig 7: Vibration of Central mass of the base

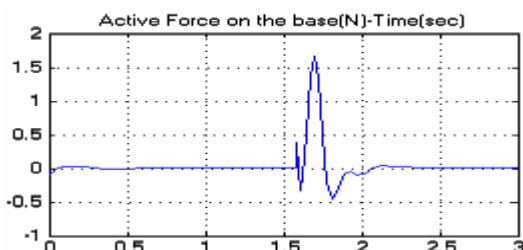


Fig 8: Control Force on the Central Mass of Base

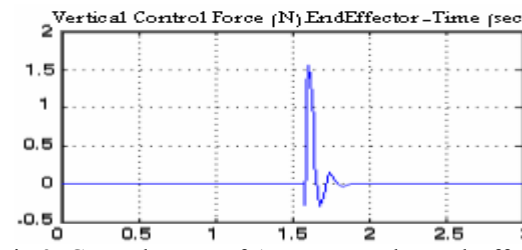


Fig 9: Control Force of Actuator on the End Effector

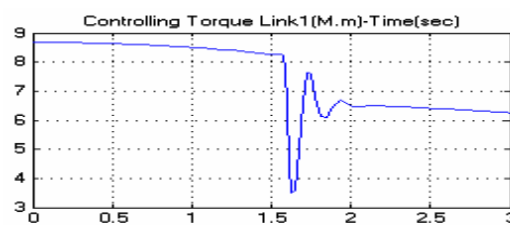


Fig 10: Control Torque of Link 1

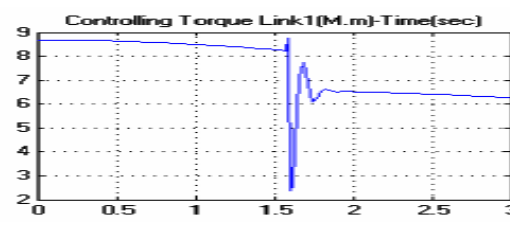


Fig 11: Control Torque of Link 1

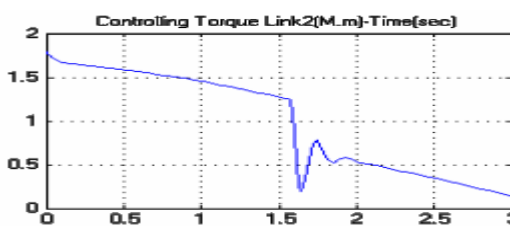


Fig 12: Control Torque of Link 2

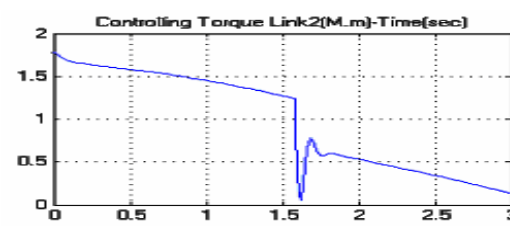


Fig 13: Control Torque of Link 2

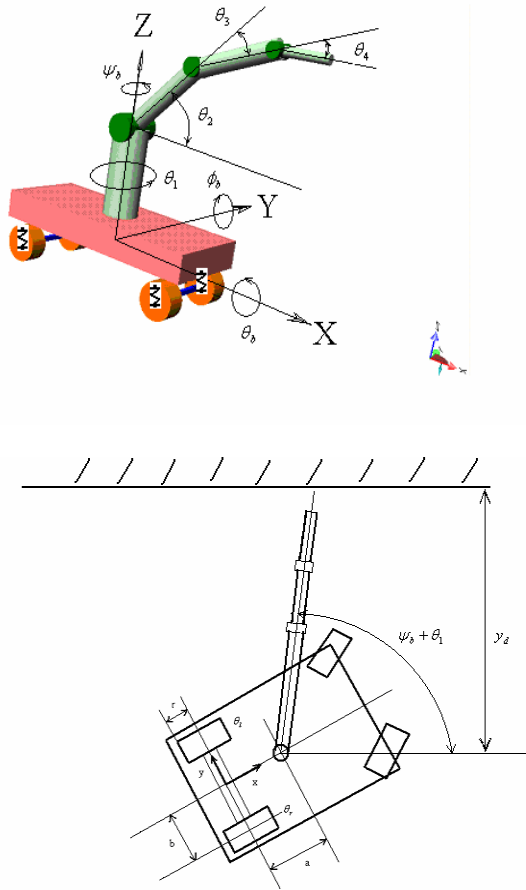


Fig. 14: Advanced FBMM model DOF's:

$[x_b \ y_b \ z_b \ \theta_b \ \phi_b \ \psi_b \ \theta_1 \ \theta_2 \ \theta_3 \ \theta_4]$

A) Advanced FBMM specifications:

$$\begin{aligned}
 m_b &= 20 \text{ kg}, a = 1 \text{ m}, b = 0.5 \text{ m} \\
 m_1 &= 5 \text{ kg}, m_2 = 5 \text{ kg}, m_3 = 3 \text{ kg}, m_4 = 2 \text{ kg} \\
 L_1 &= 2 \text{ m}, L_2 = 2 \text{ m}, L_3 = 1.5 \text{ m}, L_4 = 1 \text{ m} \\
 I_{b_x} &= 1.67 \text{ kg.m}^2, I_{b_y} = 6.67 \text{ kg.m}^2, I_{b_z} = 8.3 \text{ kg.m}^2 \\
 I_{L_1} &= 1.67 \text{ kg.m}^2, I_{L_2} = 1.67 \text{ kg.m}^2, I_{L_3} = 0.56 \text{ kg.m}^2, \\
 I_{L_4} &= 0.17 \text{ kg.m}^2
 \end{aligned}
 \tag{16}$$

B) Initial conditions

$$\begin{aligned}
 [x_b \ y_b \ z_b \ \theta_b \ \phi_b \ \psi_b \ \theta_1 \ \theta_2 \ \theta_3 \ \theta_4]_{(t=0)} &= \\
 &= \begin{bmatrix} 0 & 0 & 0 & 0 & 0 & 0 & \frac{\pi}{3} & \frac{\pi}{9} & \frac{\pi}{9} \end{bmatrix}
 \end{aligned}
 \tag{17}$$

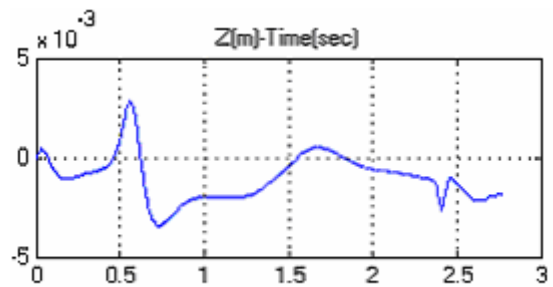
C) Equivalent Stiffness of suspension system or tyres

$$\begin{aligned}
 K(z_b) &= K_1 z_b + K_2 \\
 K_1 &= 1000 \text{ N/m}^2, K_2 = 10000 \text{ N/m}
 \end{aligned}
 \tag{18}$$

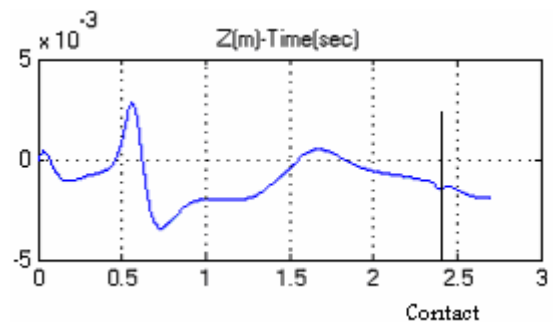
D) Desired Position and Force

Desired path is the motion of FBMM for contact process. Then End Effector of manipulator included AVEE will contact the wall. Desired End Effector trajectory on the wall is a circular path ($R=0.5 \text{ m}$) as rapid finishing process. Desired y position and force on the wall were selected as $y_d = 2 \text{ m}$ and $F_{dy} = 2.5 \text{ N}$. In this simulation, friction force was considered, because the process is a medium contact. This friction was simulated by friction coefficient on the tangential direction on the circular path.

Figure 15 shows vibration of central mass with and without AVEE and Figure 16 shows contact force. Figure 17 shows 3D motion of End Effector. We see accurately that vibration and contact force damped better with lower time and domain by AVEE under constrained motion control. (after contact) In other word, structural mass of base and robotic manipulator was deleted by AVEE and vibration damped accurately in the point of its source, impact to the wall. Therefore, control coefficients of this new control element on the End Effector are must be lower clearly. Also, damping coefficients for vibration control on the base must be selected greater values.

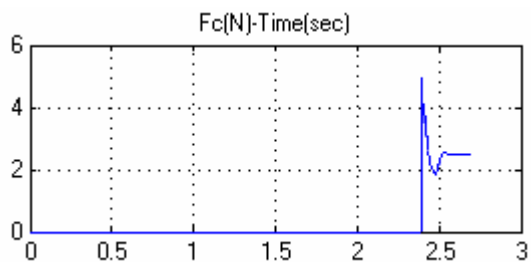


(a) Without AVEE

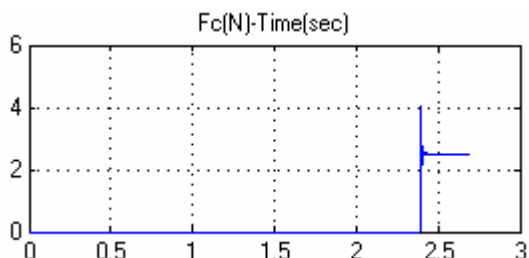


(b) With AVEE

Fig. 15: Vibration control of central mass after contact



(a) Without AVEE



(c) With AVEE

Fig. 16: Contact Force

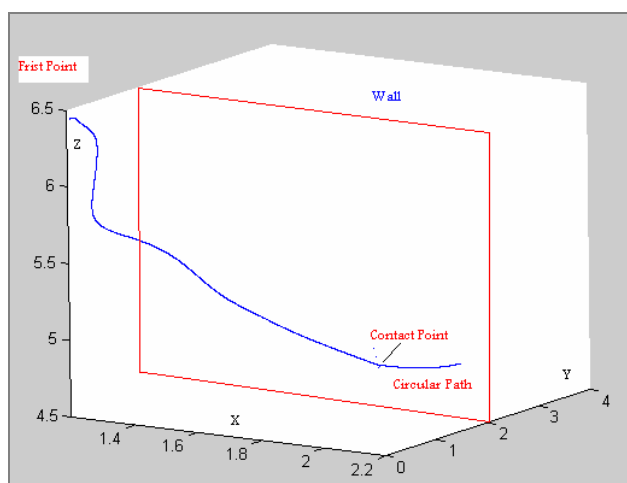


Fig. 17: 3D motion of End Effector By SMIC/AVEE

VII. CONCLUSION

Mobile manipulator applications are many and varied and will be expanded more and more. Of course, manipulator's base is flexible for this kind of manipulator and it isn't negligible. Flexibility and suspension effect cause vibration. Compliance of the base in most cases results in the loss of accuracy and limitations in achievable speeds. New active vibration control method on the End Effector (AVEE) was proposed under sliding mode impedance control for Flexible Base Mobile Manipulator (FBMM).

This proposed controller was simulated for two models. First model is a simple flexible base mobile manipulator composed of 2 DOFs planar manipulator and a single DOF moving base with flexibility in between. Second model is an advanced 10 DOF's FBMM. Simulation results show better damping response for desired position and force by

combined AVEE and new Sliding Mode Impedance Control (SMIC) comparing with Active Vibration Control on the manipulator's base (AVCB). Interesting result is lower value for feedback control coefficients of AVEE. Therefore combined SMIC/AVEE will be provided same or better desired impedance (position and force) and better damping effect at the contact point. Also, it is smaller with damping effect accurately in contact point. It is chopper with lowest effect of noise. This is the first time that this new impedance/vibration control method is proposed for FBMM.

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